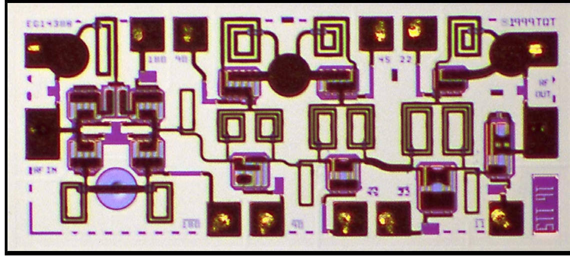
18 - 20 GHz 5-Bit Phase Shifter TGC1439A-EPU



Key Features and Performance

- 0.5um pHEMT Technology
- 18-20 GHz Frequency Range
- 3º Typical RMS Phase Shift Error
- -5 dB Typical Insertion Loss
- Control Voltage: -2.5 V to -5.0 V
- Compact 1.27 mm^2 Die Area

Primary Applications

- Phased Arrays
- Satellite Communication Systems

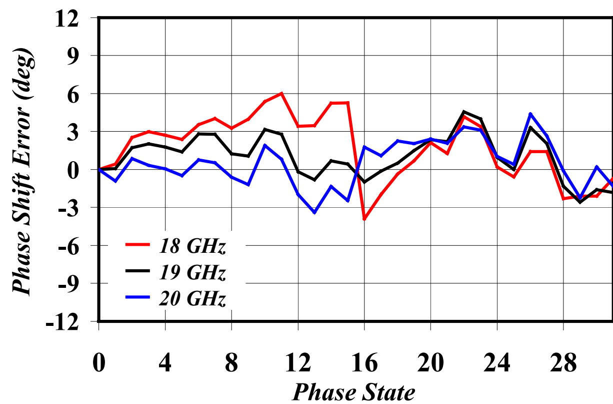
The TriQuint TGC1439A-EPU is a 5-Bit Digital Phase Shifter MMIC design using TriQuint's proven 0.5 µm Power pHEMT process to support a variety of K-Band phased array applications including satellite communication systems.

The 5-bit design utilizes a compact topology that achieves a 1.27 mm^2 die area, high performance and good tolerance to control voltage variation

The TGC1439A provides a 5-Bit digital phase shift function with a nominal -5 dB insertion loss and 3º RMS phase shift error over a bandwidth of 18-20 GHz.

The TGC1439A requires a minimum of off-chip components and operates with a -5.0 V to -2.5 V control voltage range. Each device is RF tested on-wafer to ensure performance compliance. The device is available in chip form.

TGC1439A Typical RF Performance (Fixtured)



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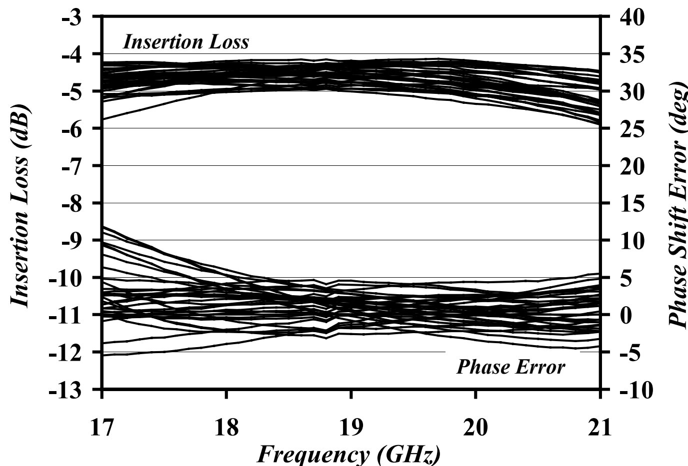
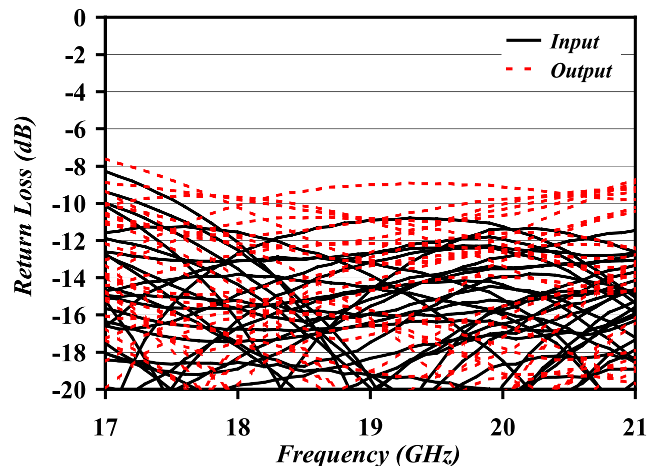


TGC1439A Typical RF Performance (Fixtured)



Note: Devices designated as EPU are typically early in their characterization process prior to finalizing all electrical and process specifications. Specifications are subject to change without notice.

Electrical Characteristics

RECOMMENDED MAXIMUM RATINGS

Symbol	Parameter	Value	Notes
V^-	Control Voltage	-8 V	
I^+	Control Current	1 mA	3/
P_D	Power Dissipation	0.1 W	
P_{IN}	Input Continuous Wave Power	20 dBm	
T_{CH}	Operating Channel Temperature	150 °C	1/, 2/
T_M	Mounting Temperature (30 seconds)	320 °C	
T_{STG}	Storage Temperature	-65 °C to 150 °C	

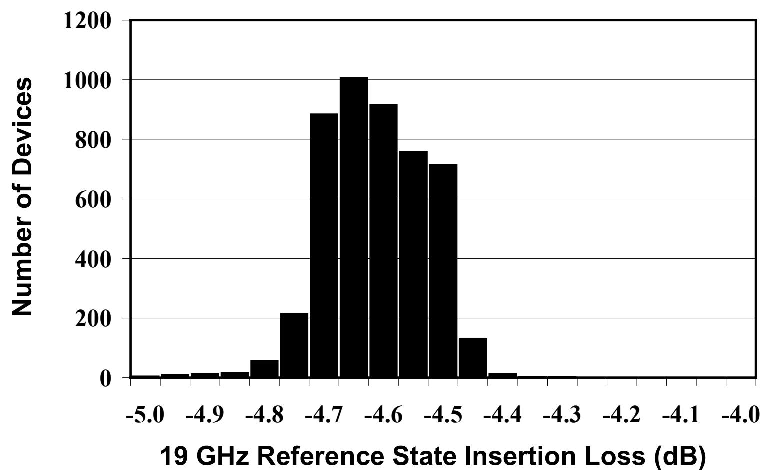
1/ These ratings apply to each individual FET

2/ Junction operating temperature will directly affect the device mean time to failure (MTTF). For maximum life it is recommended that junction temperatures be maintained at the lowest possible levels.

3/ Total current for the entire MMIC

ON-WAFER RF PROBE CHARACTERISTICS
(T_A = 25 °C ± 5°C)

Symbol	Parameter	Test Condition Vctnl=0V / -2.5V	Limit Min	Limit Nom	Limit Max	Units
IL	Insertion Loss	F = 18, 19, 20 GHz States 0 and 31	-5.5	-4.6	-4.0	dB
IRL	Input Return Loss	F = 18, 19, 20 GHz States 0 and 31		-16	-11	dB
ORL	Output Return Loss	F = 18, 19, 20 GHz States 0 and 31		-14	-11	dB
PS	Phase Shift	F = 18, 19, 20 GHz State 31	342	344	350	deg



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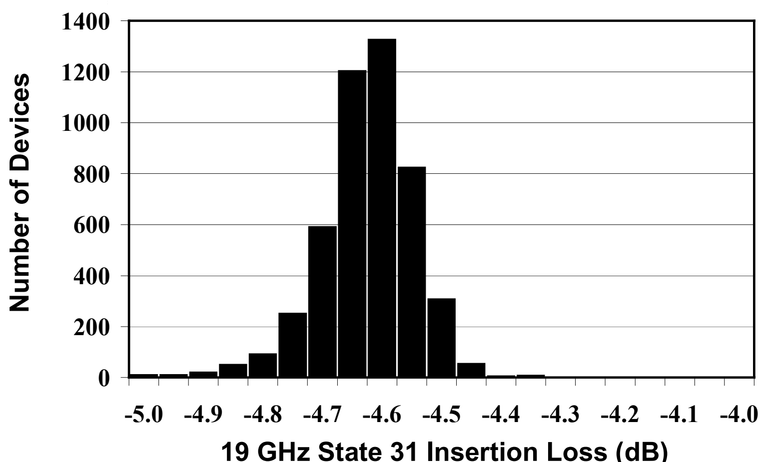

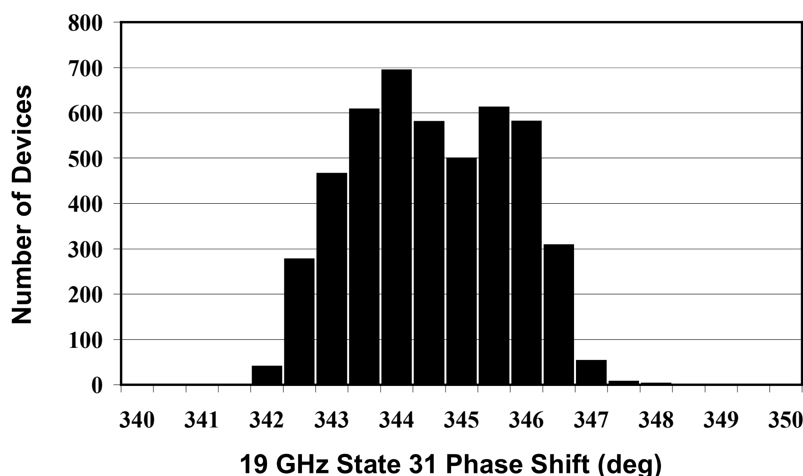

Typical Fixtured Performance Over the 18-20 GHz Band

Parameter	***Unit***	***-5.0 V***	***-2.5 V***
Mean Insertion Loss	dB	-4.9	-5.0
Mean Loss Flatness	dB	0.3	0.6
Peak Amplitude Error	dBpp	1.2	1.3
RMS Amplitude Error	dB	0.25	0.30
Peak Phase Shift Error	deg	-3 / +7	-3 / +7
RMS Phase Shift Error	deg	3.0	2.7
Loss Temp. Variation	dB/°C	-0.0048	-0.0052
Ave Input Return Loss	dB	-16	-15
Ave Output Return Loss	dB	-15	-15

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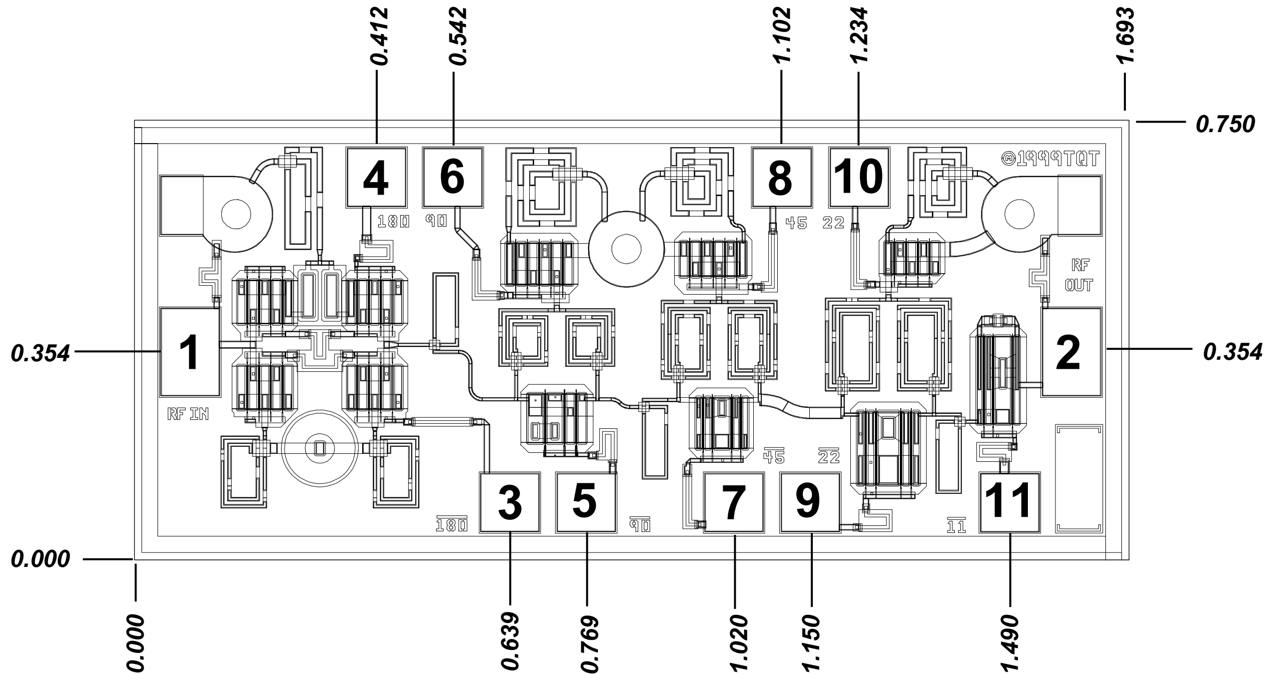
Mechanical Characteristics



Units: millimeters
Thickness: 0.1016
Chip size tolerance: +/- 0.0508
Vcntl = -5.0 V to -2.5 V
Passive device, RF IN and RF OUT designators for reference only

Bond Pad #1	*(RF IN)*	*0.100 x 0.150*
Bond Pad #2	*(RF OUT)*	*0.100 x 0.150*
Bond Pad #3	*(180º Bit ON: V= Vcntl)*	*0.100 x 0.100*
Bond Pad #4	*(180º Bit ON: V= 0.0V)*	*0.100 x 0.100*
Bond Pad #5	*(90º Bit ON: V= Vcntl)*	*0.100 x 0.100*
Bond Pad #6	*(90º Bit ON: V= 0.0V)*	*0.100 x 0.100*
Bond Pad #7	*(45º Bit ON: V= Vcntl)*	*0.100 x 0.100*
Bond Pad #8	*(45º Bit ON: V= 0.0V)*	*0.100 x 0.100*
Bond Pad #9	*(22.5º Bit ON: V= Vcntl)*	*0.100 x 0.100*
Bond Pad #10	*(22.5º Bit ON: V= 0.0V)*	*0.100 x 0.100*
Bond Pad #11	*(11.25º Bit ON: V= Vcntl)*	*0.100 x 0.100*

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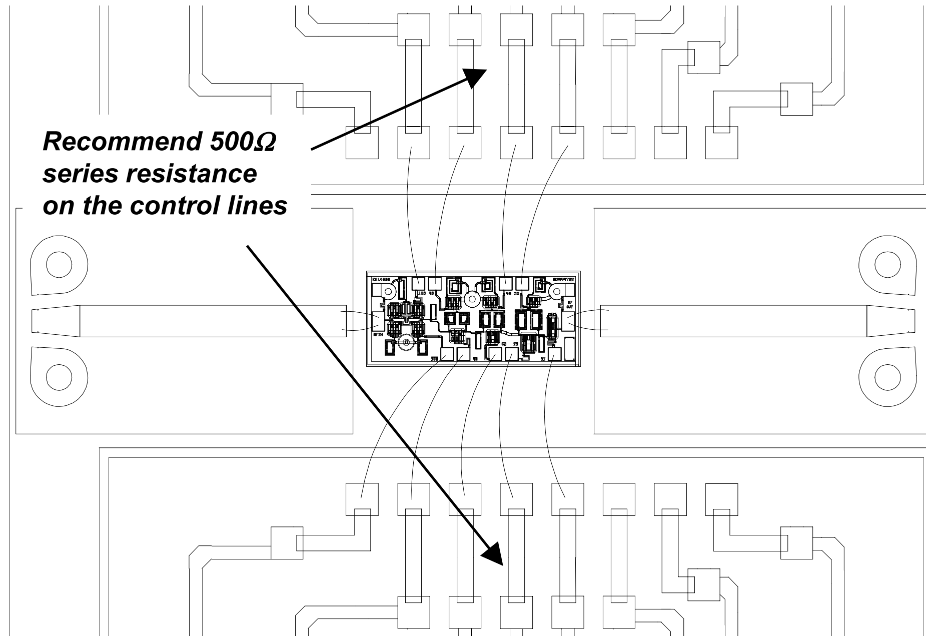

Chip Assembly and Bonding Diagram

Reflow process assembly notes:

- AuSn (80/20) solder with limited exposure to temperatures at or above 300°C
- alloy station or conveyor furnace with reducing atmosphere
- no fluxes should be utilized
- coefficient of thermal expansion matching is critical for long-term reliability
- storage in dry nitrogen atmosphere

Component placement and adhesive attachment assembly notes:

- vacuum pencils and/or vacuum collets preferred method of pick up
- avoidance of air bridges during placement
- force impact critical during auto placement
- organic attachment can be used in low-power applications
- curing should be done in a convection oven; proper exhaust is a safety concern
- microwave or radiant curing should not be used because of differential heating
- coefficient of thermal expansion matching is critical

Interconnect process assembly notes:

- thermosonic ball bonding is the preferred interconnect technique
- force, time, and ultrasonics are critical parameters
- aluminum wire should not be used
- discrete FET devices with small pad sizes should be bonded with 0.0007-inch wire
- maximum stage temperature: 200°C

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.